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APPLICATION NO.	PLICATION NO. FILING DATE		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/696,204		10/29/2003	Ying Zhou	ITL.1024US (P16711)	7312	
21906	7590	03/23/2005		EXAM	EXAMINER	
TROP PR	JNER &	HU, PC	ESTRADA,	ESTRADA, MICHELLE		
8554 KATY	FREEW	ΑY				
SUITE 100			ART UNIT	PAPER NUMBER		
HOUSTON	, TX 770	024	2823			
				DATE MAILED: 02/22/2005		

Please find below and/or attached an Office communication concerning this application or proceeding.

		Appl	ication No.	Applicant(s)					
			96,204	ZHOU ET AL.					
Off	ice Action Summary	Exan	niner	Art Unit					
			elle Estrada	2823					
The N Period for Reply	IAILING DATE of this commu I	nication appears o	n the cover sheet with t	he correspondence a	ddress				
THE MAILIN - Extensions of ti efter SIX (6) MC - If the period for - If NO period for - Failure to reply Any reply receiv	IED STATUTORY PERIOD IS DATE OF THIS COMMUN me may be available under the provision DNTHS from the mailing date of this com reply specified above is less than thirty (reply is specified above, the maximum s within the set or extended period for reply ded by the Office later than three months erm adjustment. See 37 CFR 1.704(b).	IICATION. s of 37 CFR 1.136(a). In munication. 30) days, a reply within the tatutory period will apply y will, by statute, cause the	no event, however, may a reply lestatutory minimum of thirty (30 and will expire SIX (6) MONTHS application to become ABAND	pe timely filed) days will be considered tim from the mailing date of this ONED (35 U.S.C. § 133).					
Status									
1)⊠ Respo	nsive to communication(s) fil	ed on 28 Decemb	er 2004.						
	2a)⊠ This action is FINAL . 2b)□ This action is non-final.								
3)☐ Since t	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.								
Disposition of C	Claims								
4a) Of t 5) ☐ Claim(: 6) ☑ Claim(: 7) ☑ Claim(:	s) <u>1-35</u> is/are pending in the the above claim(s) is/s s) is/are allowed. s) <u>1-4,11-13,19,21,26,31,32,</u> s) <u>5-10,14-18,20,22-25, 27-3</u> s) are subject to restri	are withdrawn fron 34 and 35 is/are r 0 and 33 is/are ob	ejected. ojected to.						
Application Pap	ers								
9)☐ The spe	ecification is objected to by the	ne Examiner.							
10)☐ The dra	wing(s) filed on is/are	: a)□ accepted o	or b) \square objected to by t	he Examiner.					
	nt may not request that any obje	`		, ,					
	ement drawing sheet(s) includin :h or declaration is objected t	-		·					
Priority under 3	5 U.S.C. § 119								
12)□ Acknow a)□ <u>A</u> II	rledgment is made of a claim b)☐ Some * c)☐ None of:		· · ·	9(a)-(d) or (f).					
_	Certified copies of the priority			action No					
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_	application from the Internation	• •		erved in this reactorie	ii Otage				
	attached detailed Office action	· ·		eived.					
Attachment(s)			🗖						
	rences Cited (PTO-892) sperson's Patent Drawing Review (I	PTO-948)	4) ∐ Interview Sumn Paper No(s)/Ma						
	sclosure Statement(s) (PTO-1449 o			nal Patent Application (PT	O-152)				

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DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 1-4, 11-13, 19, 21, 26, 32, 34 and 35 are rejected under 35 U.S.C. 102(e) as being anticipated by Yao (6,679,996).

With respect to claim 1, Yao discloses soaking a substrate (1) having a dielectric (2) deposited thereon in a salt solution (Col. 7, lines 12-25), said dielectric having a first dielectric constant; and depositing an oxide (3) on said dielectric, said oxide having a second dielectric constant different from the first dielectric constant.

With respect to claim 2, Yao discloses wherein depositing an oxide on said dielectric includes depositing aluminum oxide on said dielectric (Col. 9, lines 17-32), the Examiner clarifies that Yao discloses using a fluoride ion capturing agent added to the aqueous solution to deposit the layer of a corresponding metal oxide or a solid solution thereof, one of these ion capturing agent can be aluminum chloride, therefore aluminum oxide will be formed on the dielectric layer since aluminum oxide is the corresponding metal oxide of aluminum chloride (Col. 9, lines 17-33).

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With respect to claim 3, Yao discloses wherein soaking said substrate in said salt solution includes soaking said substrate in a salt solution comprising an aluminum salt (Col. 9, lines 29-32 and 58-61).

With respect to claim 4, Yao discloses wherein soaking said substrate in said salt solution comprising said aluminum salt includes soaking said substrate in a aqueous solution comprising the capturing agent, therefore the salt solution comprises aluminum chloride dissolved in water (Col. 7, lines 15-25).

With respect to claim 11, Yao discloses exposing a dielectric (2) deposited on a substrate to a salt solution; and causing an oxide which is different from said dielectric on said substrate to form on said dielectric (Col. 7, lines 12-20).

With respect to claim 12, Yao discloses including exposing said dielectric on said substrate to an aluminum salt solution (Col. 9, lines 29-31).

With respect to claim 13, Yao discloses including exposing said dielectric on said substrate to an aluminum chloride solution (Col. 9, lines 29-31).

With respect to claim 19, Yao discloses removing said substrate from said salt solution and rinsing (Col. 11, lines 1-8).

With respect to claim 21, Yao discloses depositing a dielectric (2) on a substrate (1) using a first method of deposition; and depositing an oxide (3) on said dielectric by immersing said substrate in a salt solution (Col. 7, lines 12-30), said deposition by immersing different from said first method of deposition.

With respect to claim 26, Yao discloses wherein depositing an oxide on said dielectric includes depositing aluminum oxide on said dielectric by immersing said

Substrate in an aluminum salt solution (Col. 9, lines 17-32), the Examiner clarifies that Yao discloses using a fluoride ion capturing agent added to the aqueous solution to deposit the layer of a corresponding metal oxide or a solid solution thereof, one of these ion capturing agent can be aluminum chloride, therefore aluminum oxide will be formed on the dielectric layer since aluminum oxide is the corresponding metal oxide of aluminum chloride (Col. 9, lines 17-33).

With respect to claim 32, Yao discloses exposing a semiconductor substrate (1) to a salt solution to form at least a portion of a film (3) on the surface of the substrate, the film or portion thereof including aluminum oxide as the primary film material (Col. 9, lines 53-60).

With respect to claim 34, Yao discloses including exposing said semiconductor substrate to an aluminum salt solution (Col. 9, lines 29-32 and 58-61).

With respect to claim 35, Yao discloses including depositing a dielectric (2) that is not aluminum oxide on the substrate (1) before exposing the substrate to the salt solution (Col. 3, lines 20-35).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 31 is rejected under 35 U.S.C. 103(a) as being unpatentable over Yao (6,679,996) as applied to claims 1-4, 11-13, 19, 21, 26, 32, 34 and 35 above, and further in view of Ishikawa et al. (2004/0200962).

Yao does not disclose wherein depositing a dielectric on a substrate includes using a chemical vapor deposition technique to deposit said dielectric. Yao's dielectric layer is a polymer, preferably a resist.

Ishikawa et al. teach that resists can be deposited by CVD method (See Paragraph [0065]).

It would have been within the scope of one of ordinary skill in the art to combine the teachings of Yao and Ishikawa et al. to enable the dielectric formation step of Yao to be performed according to the teachings of Ishikawa et al. because one of ordinary skill in the art would have been motivated to look to alternative suitable methods of performing the disclosed dielectric formation step of Yao and art recognized suitability for an intended purpose has been recognized to be motivation to combine. See MPEP 2144.07.

Allowable Subject Matter

Claims 5-10, 14-18, 20, 22-25, 27-30 and 33 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

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Response to Arguments

Applicant's arguments filed 12/28/04 have been fully considered but they are not persuasive. Applicant argues that Yao fails to specifically disclose depositing an oxide on a dielectric, the oxide and dielectric having different dielectric constants. However, Yao discloses forming a dielectric layer 2 which can be a polymer and depositing an oxide layer (3), which is a metal oxide (Col. 3, lines 25-35 and Col. 5, lines 62-65). These two layers will have different dielectric constants.

Applicant argues that Yao fails to disclose forming a precipitate on a dielectric. However, Yao discloses forming oxide 3 on layer 2, which comprises a dielectric layer.

Applicant argues that is unclear from the Office action where in Yao aluminum chloride is disclosed as a fluoride ion capturing agent, and points out Col. 6, lines 11-45. However, the Examiner believes that Applicant has mistaken references, and is referring to Col. 6, lines 11-45 of Yao (5,830,242). The Examiner based the rejection on the reference of Yao (6,679,996) and pointed to Col. 9, lines 17-33 for the ion capturing agent on the Office Action mailed 10/5/04.

Applicant argues that Yao fails to disclose forming aluminum oxide as the main oxide in a precipitate and on a semiconductor substrate. However, Applicant is directed to Col. 3, lines 20-60 (Yao 6,679,996) where is disclosed that the precipitate is formed in a semiconductor substrate; and to Col. 9, line 53 where is disclosed that the precipitate is mainly aluminum oxide.

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Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Michelle Estrada whose telephone number is 571-272-1858. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 571-272-1855. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 571-272-2800.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

George Fourson
Primary Examiner
Art Unit 2823

March 10, 2005